

Proton Plan ORBUMP and 400 MeV Upgrades WBS 1.2.2 Director's Review August 2005

J. Lackey/F. G. Garcia

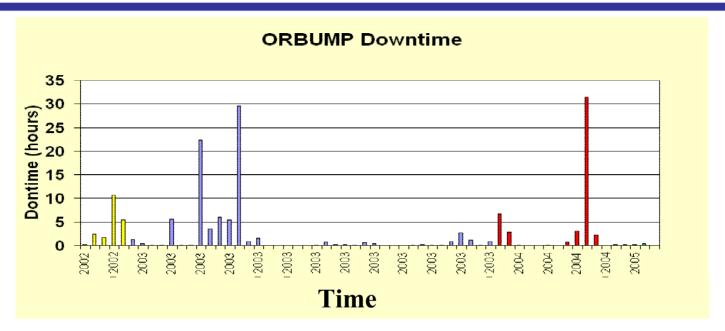


Booster supports

- > Pbar production ~ 4.5X1012 protons/cycle @ ~1 Hz
- > Collider protons ~ 3-4X1011 protons/coal. bunch
- MiniBooNE ~ 3-4x10¹² protons/cycle @ ~2-3 Hz
- NuMI ~ 4.5x10¹² protons/cycle @ ~2.0 Hz
- > Switchyard 120 ~ 8.3x1011 protons/cycle @ ~ 0.3 Hz
- · Protons deliverable by Booster are limited by
 - > Activation of beam line components
 - > Rate at which certain elements are capable of running
 - Currently limited to 7.5 Hz
 - The injection bump (OrBump) system is a limiting factor!

OrBump limitations

- > Magnets
 - Limited to 7.5 Hz due to temperature
- > Power supply:
 - Charging supply reliability questionable beyond ~ 9 Hz
 - Age of electrical components raise longevity concerns



- Rate limitation was not a concern prior to MiniBooNE.
- Initial efforts to achieve higher rates was moderately successful.
 - > Common failures were temperature related
 - > Limiting factor was power supply component failures
 - > In May'04 all the capacitors were changed and the power supply failures decreased considerably



OrBump Temperature History

Power Supply

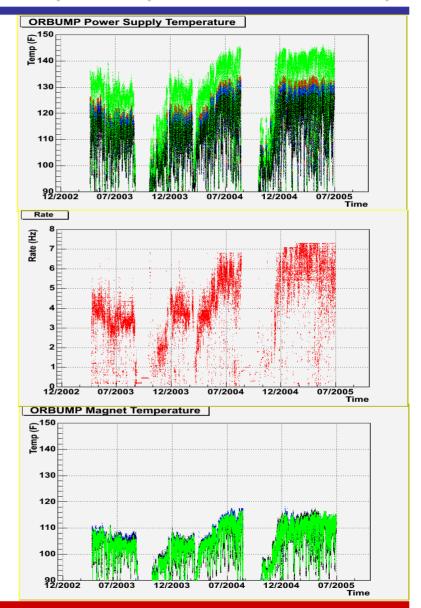
Better stability even at high temperature

Rate

- > Increase from
 - 3-4.5 Hz range to
 - · 5-6.5 Hz range

Magnets

- Temperature of the magnets became the limiting factor
- Biggest concern is how soon the magnets will fail due to thermal cycling





- · GOAL
 - > Making Booster capable of running beam at 15 Hz
- Requirements
 - > Eliminate OrBump limiting factors
 - > OrBump System Improvements
 - OrBump Power Supply (WBS 1.2.2.2)
 - Operational supply capable of running at 9 Hz
 - New supply been built will be capable of running at 15 Hz
 - OrBump Magnets (WBS 1.2.2.1)
 - Operational magnets are limited by heating to 7.5 Hz
 - New magnets will be LCW cooled for temperature regulation



OrBump Power Supply



Power Supply specifications

- Nominal pulse amplitude = 15 kA
- Maximum pulse amplitude = 17.5 kA
- Maximum flat top duration = $50 \mu sec$
- Rise/Fall time
 - > Minimum = 30 μsec
 - > Maximum = 40 μsec
- Nominal repetition rate = 15 Hz

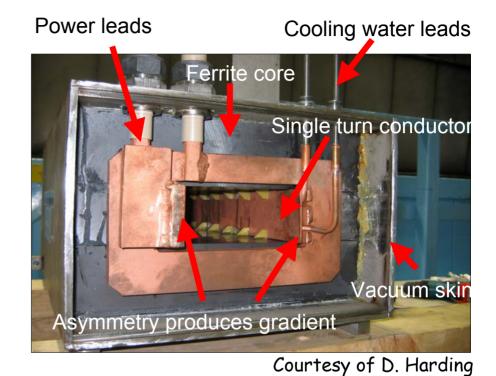
Current Status

- Charging supply assembly underway
- Cabinet assembly underway
- Ready for installation beginning of Nov'05



OrBump Magnet

Parameter	Value	Units		
∫By dl @ 15 kA	0.1676	T-m		
Ferrite length	523.3	mm		
Effective length	558.5	mm		
Aperture gap	65.1	mm		
Aperture width	135.1	mm		
Inductance	1.83	μН		
Resistance	<1	$m\Omega$		
Quadrupole	1×10 ⁻⁴	mm ⁻¹		



Current Status

- · 4(6) magnets assembled
- · Field shape development continues
- Magnets production complete in Oct'05

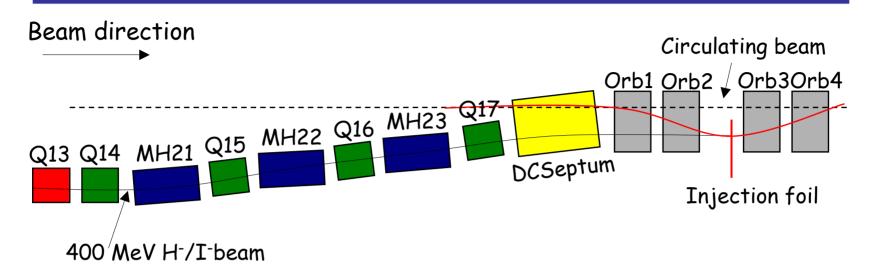
Backups 29,30



- OrBump replacement is targeted for 2005 shutdown
- Initial plan
 - > Replace 4 magnets and 1 power supply in current injection scheme
- The injection girder is a high radiation area and presents a hazard during installation
 - > L1 activation is ~ 600 mr/hr @ 1 foot
 - > Plan evolves to remove the girder and install a new one
- Complete rebuild of the injection section is needed
 - > Alternative injection scheme layout was pursued
 - Workable layout was found
 - (BEAMS-DOC-1784-v1, M. Popovic)



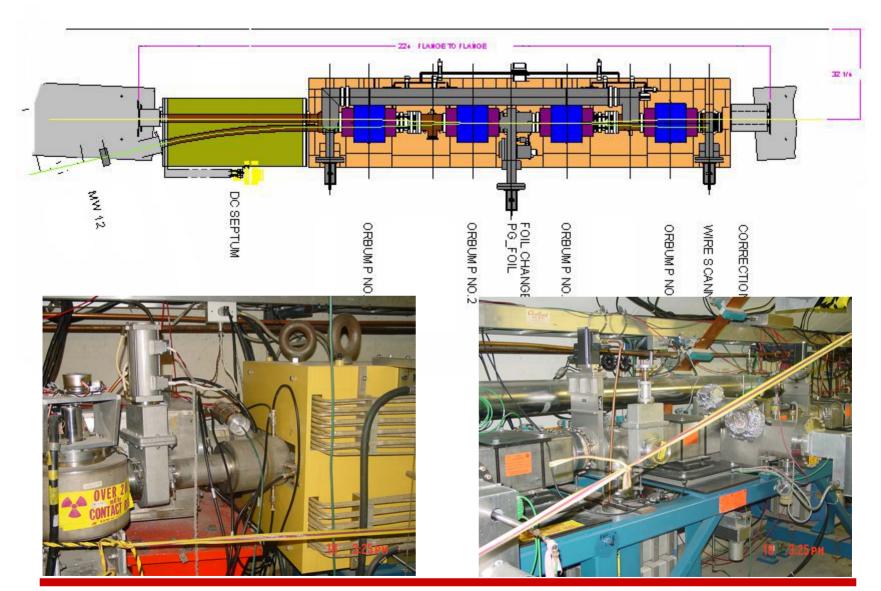
Current Injection Scheme



- · 4-bump injection scheme
- DC septum magnet bends the injected beam parallel to the circulating beam
- The circulating beam is "bumped out" so that the injected and circulated beam pass together through the injection foil

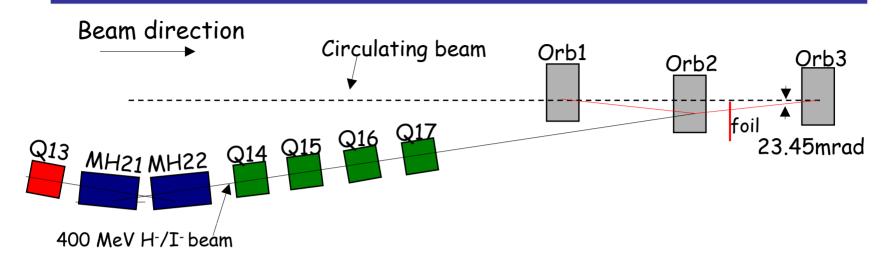


Current Injection Girder



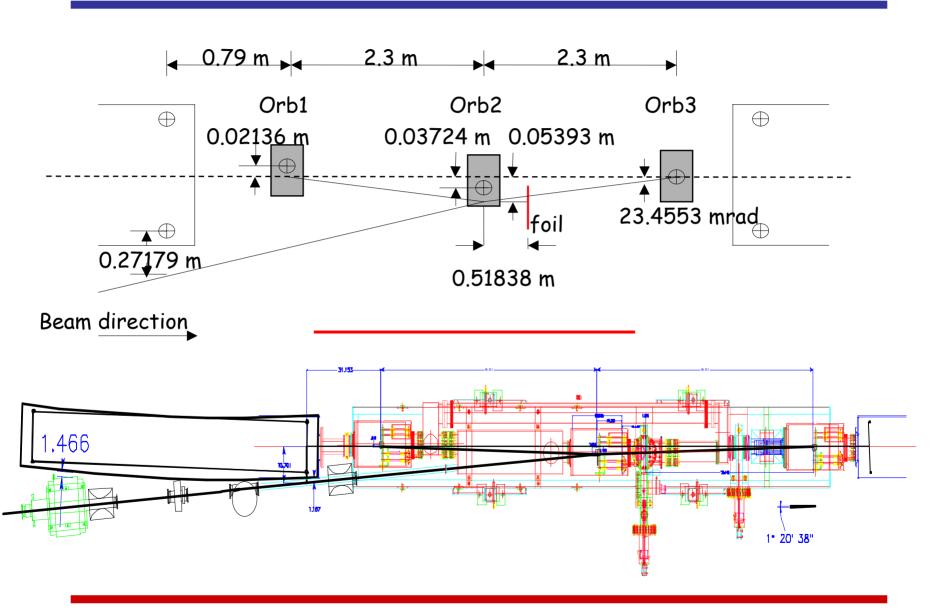


New Injection Scheme



- 3-bump injection scheme
- · No need for DC septum magnet
 - > Reducing the radiation hazard during installation
 - Increase vertical aperture entering OrBump from 1.5" to 3.25"
- · Line is simpler
 - > Less components
 - The 3-bump scheme requires only 15 kA rather than 30 kA from the power supply
 - > OrBump magnets are further apart from each other
 - Reduce focusing edge effects

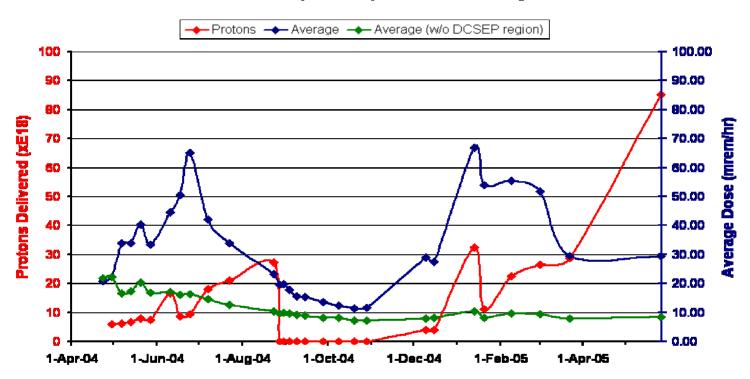




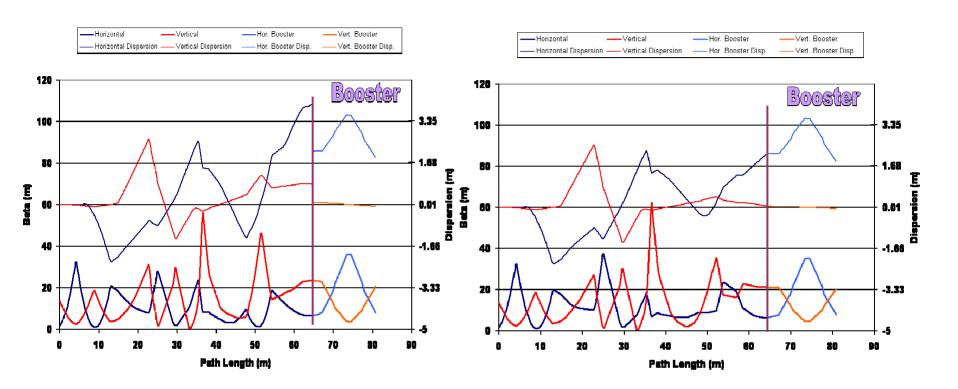


Transfer Line Activation History

400 MeV (Booster) Activation History



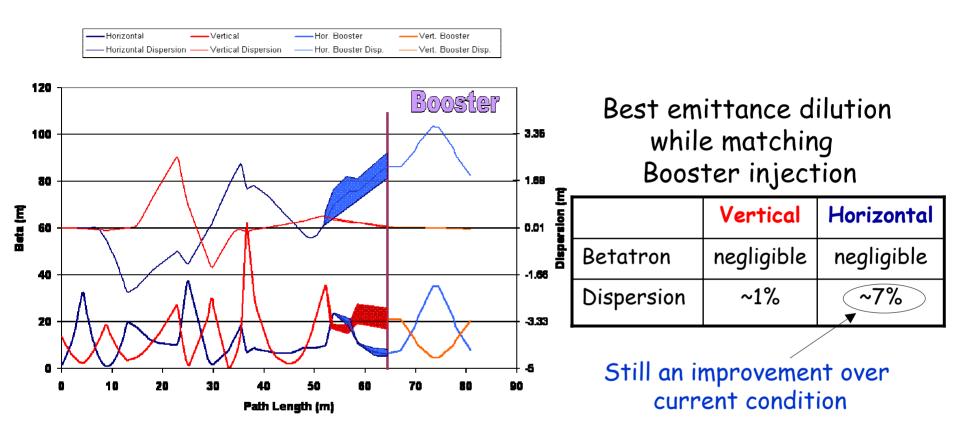
~70% reduction in tunnel activation without DC Septum



- Vertical beta function is somewhat smaller (~23%)
- Better matching to the horizontal/vertical dispersion seems promising



New Injection (cont.)



The lattice matching section shows flexibility for Booster injection tune (bands represent \pm 20% variation of injection beam parameters)



Other sources of emittance dilution

Besides the amplitude and dispersion mismatch, there are other potential sources of emittance dilution

Possible sources	Emittance dilution (%)				
Power supply jitter (± 1% stability)	~1% (position only) ~10% (angle and position)				
Incoming beam variation	~10% (both planes)				
OrBump magnet (Quadrupole component)	negligible				
Closed orbit variation	negligible				

Backups 26,27,28

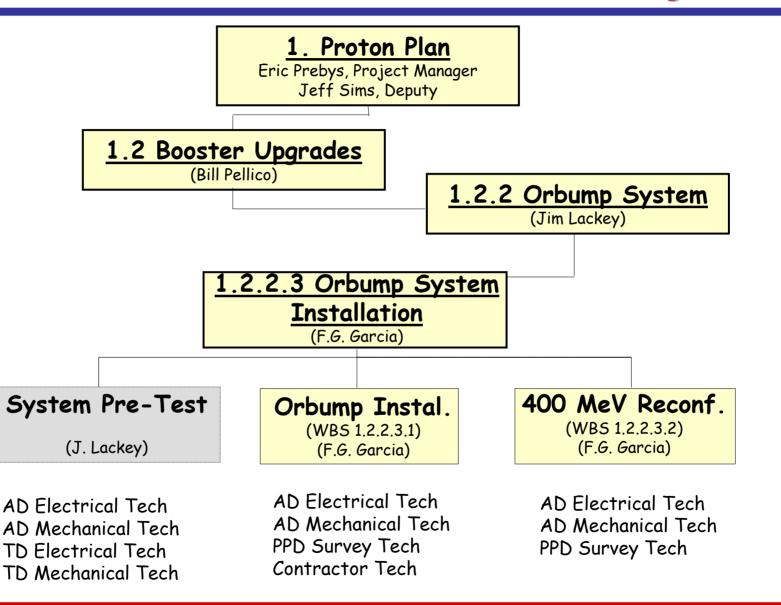


- 100% duty factor operation possible
- Edge focusing effects minimized
 - Vertical Lattice distortions reduced
 - > Smaller beam size
 - > Larger effective aperture
- PS current reduced by 1/2
 - > Lower rms current
 - > Lower heating effects
- Injection apertures larger
 - > Injection Beam losses lower
 - > Injecting onto ideal machine orbit
 - > Injection phase space painting now a possibility



- We plan to establish beam onto 8 GeV dump prior normal operation resumes
 - > Prerequisite of commissioning
 - After reinstallation of line components a series of checks will be carried out, such as
 - Magnet connections and polarities
 - Visual check and confirmation that all LCW valves are working properly
 - Visual inspection of the vacuum valve positions
 - Instrumentation function and readout polarity
 - And so on....
 - > Initial beam commissioning
 - · Start at lower intensity and rep rate
 - Establish beam onto Linac dump
 - Transport beam onto injection girder. Apply theoretical tune on quads belonging to the matching section to Booster
 - Initial checks of beam optics and rough correction as needed
 - Correct beam trajectories along transport using correctors
 - Evaluate any beam loss concerns and tightest aperture clearance
 - Establish circulating beam
 - Increase intensity and start tuning for efficiency
 - > Commissioning period expect to last a couple of weeks





Personnel





Uniq	WBS	Name	St	Fin	%	Float	2005 2006									
22		***************************************				18-07-07/35-41	4	1	2	3		4	1	2	3	4
10	1.2.2	OrBump System	9/30/04	1/25/06	68%	0.000		—					24-34	_		
38	1.2.2.1	OrBump System Magnets Design & Production	9/30/04	11/14/05	76%	12 d	ļ	—					4			
202	1.2.2.1.1	OrBump Magnet TD Division FY04 Costs	9/30/04	9/30/04	100%	0 d										
139	1.2.2.1.2	OrBump Magnets	10/1/04	10/6/05	85%	12 d		•								
142	1.2.2.1.3	OrBump Stripline	4/1/05	10/12/05	59%	20 d		N.		T						
146	1.2.2.1.4	OrBump Girder	4/1/05	11/14/05	45%	12 d				L			-			
39	1.2.2.2	OrBump System Power Supply	1/25/05	11/9/05	58%	32 d				. M/s			j			
40	1.2.2.2.1	OrBump P.S. Specifications	1/25/05	1/31/05	100%	0 d							M.			
41	1.2.2.2.2	OrBump P.S. Simulations	2/1/05	2/14/05	100%	0 d										
404	1.2.2.2.3	OrBump P.S. Design Review Preparation	5/9/05	6/7/05	100%	0 d										
405	1.2.2.2.4	OrBump P.S. Design Review	6/15/05	6/15/05	100%	0 d										
45	1.2.2.2.5	OrBump P.S. Cabinet Layout	6/1/05	8/31/05	50%	32 d										
46	1.2.2.2.6	OrBump P.S. General Procurement	3/1/05	8/31/05	94%	32 d			0100	, <u>, , , , , , , , , , , , , , , , , , </u>						
42	1.2.2.2.7	OrBump P.S. Procure Capacitors	2/15/05	9/1/05	20%	63 d							2			
44	1.2.2.2.8	OrBump Charging Power Supply Assembly	4/11/05	8/31/05	90%	32 d										
47	1.2.2.2.9	OrBump P.S. Cabinet Assembly	9/27/05	10/31/05	0%	32 d						Ъ	4			
43	1.2.2.2.10	OrBump P.S. Assemble Controls	6/17/05	9/26/05	32%	32 d							<u></u>			
278	1.2.2.2.11	OrBump P.S. Initial Testing	11/1/05	11/9/05	0%	32 d										
309	1.2.2.2.12	OrBump Power Supply Ready for Installation	11/9/05	11/9/05	0%	32 d							11/9)		
342	1.2.2.3	OrBump Syst Installation	5/2/05	12/21/05	56%	11 d							V			
175	1.2.2.3.1	Installation	11/10/05	12/12/05	0%	15 d							W	8		
386	1.2.2.3.2	400 MEV Line Reconfiguration	5/2/05	12/21/05	71%	11 d								J		
789	1.2.2.4	Commission OrBump System	1/11/06	1/25/06	0%	623 d				· .						
791	1.2.2.5	OrBump System Commissioned	9/30/04	9/30/04	0%	395 d		Å 9/30								



Uniq	WBS	Name	Esc SWF	Esc M&S	Cont %	
10	1.2.2	OrBump System	\$191,548	\$130,635	29%	
38	1.2.2.1	OrBump System Magnets Design & Production	\$0	\$0	0%	
202	1.2.2.1.1	OrBump Magnet TD Division FY04 Costs	\$0	\$0	0%	
139	1.2.2.1.2	OrBump Magnets	\$0	\$0	0%	
142	1.2.2.1.3	OrBump Stripline	\$0	\$0	0%	
146	1.2.2.1.4	OrBump Girder	\$0	\$0	0%	
39	1.2.2.2	OrBump System Power Supply	\$118,799	\$122,000	28%	
40	1.2.2.2.1	OrBump P.S. Specifications	\$2,049	\$0	0%	
41	1.2.2.2.2	OrBump P.S. Simulations	\$2,781	\$0	0%	
404	1.2.2.2.3	OrBump P.S. Design Review Preparation	\$11,682	\$0	0%	
405	1.2.2.2.4	OrBump P.S. Design Review	\$556	\$0	0%	
45	1.2.2.2.5	OrBump P.S. Cabinet Layout	\$13,212	\$0	40%	
46	1.2.2.2.6	OrBump P.S. General Procurement	\$1,669	\$93,000	20%	
42	1.2.2.2.7	OrBump P.S. Procure Capacitors	\$2,781	\$29,000	40%	
44	1.2.2.2.8	OrBump Charging Power Supply Assembly	\$20,568	\$0	20%	
47	1.2.2.2.9	OrBump P.S. Cabinet Assembly	\$28,022	\$0	40%	
43	1.2.2.2.10	OrBump P.S. Assemble Controls	\$27,375	\$0	40%	
278	1.2.2.2.11	OrBump P.S. Initial Testing	\$8,102	\$0	40%	
309	1.2.2.2.12	OrBump Power Supply Ready for Installation	\$0	\$0	0%	
342	1.2.2.3	OrBump Syst Installation	\$61,765	\$8,635	31%	
175	1.2.2.3.1	Installation	\$21,188	\$8,635	40%	
386	1.2.2.3.2	400 MEV Line Reconfiguration	\$40,577	\$0	24%	
789	1.2.2.4	Commission OrBump System	\$10,984	\$0	40%	
791	1.2.2.5	OrBump System Commissioned	\$0	\$0	0%	

RunTT



- Installation is scheduled to happen during holiday season
 - > Available manpower could be reduced due to vacation request during holiday season
 - For instance, if 2 people take vacation during holiday the project will slide for ~1.3 days
- There is always a risk for manpower been removed from one task to resolve a crisis situation at another task.



- Risk 1: Expose workers to a high radiation area
 - > <u>Mitigation</u>: Follow ALARA. Plan under development.
 - Plan the tasks carefully
 - Conduct a radiation survey 1 week prior the job start
 - After removal of components, redo survey and respond to the findings accordingly
- Risk 2: Poor transmission into Booster due to change on injection scheme
 - <u>Mitigation</u>: Internal review was conducted in Apr'05. No major concerns were raised related to the injection scheme and magnet reorganization. One could overcome the poor transmission by tuning.
- · Risk 3: Infant mortality of the new equipment
 - Mitigation: Bench testing prior to installation and commissioning period will be performed on the magnets and power supply.



- OrBump magnets and power supply need to be upgraded in order to allow Booster achieve operations at 15 Hz.
- A new injection scheme has been proposed
 - > Benefits of 3-bump injection scheme
- OrBump installation and 400 MeV reconfiguration will take place during next shutdown.
- Project duration fits into the framework of the 2005 shutdown



BACKUP SLIDES

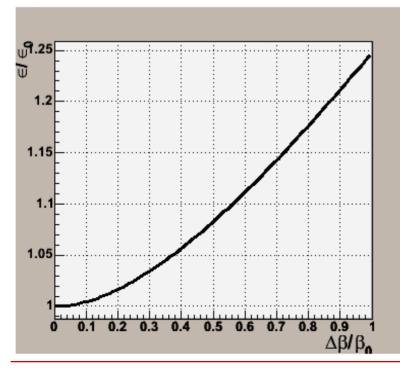
Emittance dilution

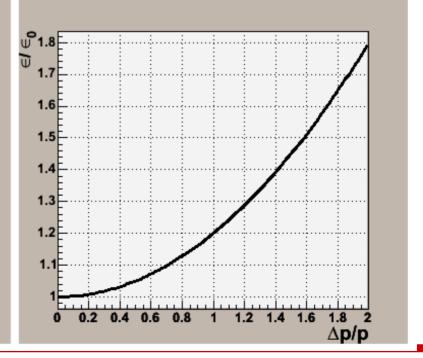
$$\in / \in_{\theta} = 1 - \frac{\det \Delta J}{2}$$

$$\det \Delta J = -\frac{(\Delta \beta / \beta_{\theta})^{2} + (\Delta \alpha - \alpha_{\theta} (\Delta \beta / \beta_{\theta}))^{2}}{1 + \Delta \beta / \beta_{\theta}}$$

Dispersion Mismatch

$$\det \Delta J = -\frac{\Delta D^2 + (\Delta D \alpha_0 + \Delta D p \beta_0)^2}{\sigma_0^2} \left(\frac{\Delta p}{p}\right)^2$$



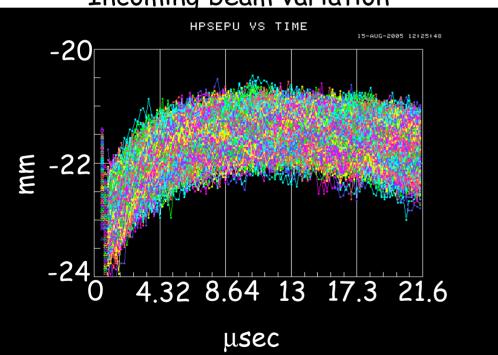




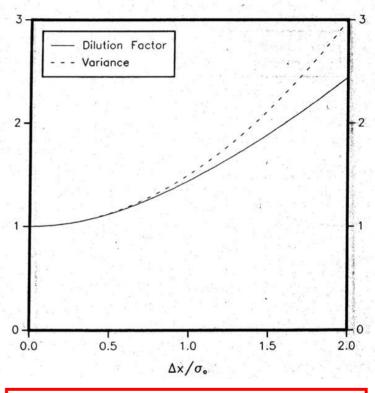


• Power supply jitter: $\pm 1\%$ $\Delta x_{eq} = 1.5 \text{ mm}$ $\Delta x' = 0.2 \text{ mrad}$

Incoming beam variation



Comparison of Variances with Dilution Factors
(a) Positon Mismatch



$$\Delta x_{eq} = \sqrt{(\Delta x^2 + (\beta \Delta x' + \alpha \Delta x)^2)}$$

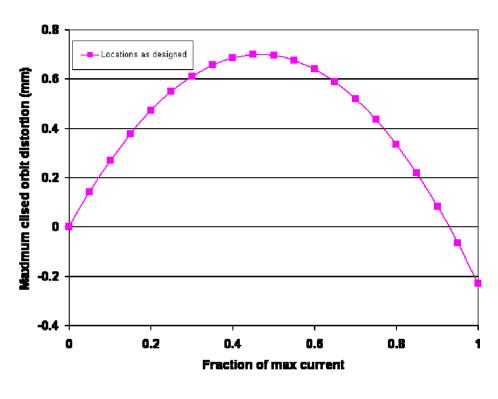
Reference: M.J. Syphers, Injection Mismatch and Phase Space Dilution, p29



The result of the beam passing through different locations of the quadrupole field is a net dipole effect on the closed orbit

- The amplitude of this dipole error changes as the OrBump power supply ramps down
- The maximum distortion is ~ 0.7mm

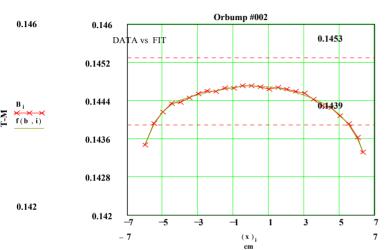
Closed Orbit Distortion



$$x_{\text{max}} = \Delta\Theta * \sqrt{\frac{\beta_{x \text{max}} \beta_{x \text{min}}}{\sin(\pi \mu_x)}}$$

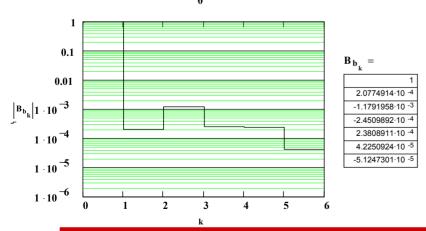
Field Measurements

OLD

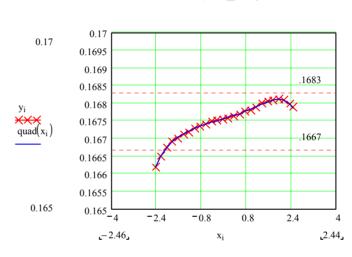


FIELD COMPONENT MAGNITUDES AT 1 inch.

$$X := 2.54 \qquad B_{b_k} := \frac{b_k}{b_0} \cdot X^k$$

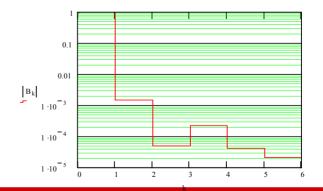


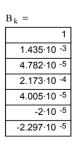
NEW



FIELD COMPONENT MAGNITUDES AT 1 inch.

$$X := \frac{25.4 \cdot 1}{25.4}$$
 $B_k := \frac{b_k}{b_0} \cdot X^k$







Operational OrBumpS

- \triangleright Designed to run at 15 kA max, 300 A_{rms} ,
- > 20% duty factor. NO cooling.
- > Presently running at ~50% duty factor.
- > Heating, Injection Error, Sextupole, Radiation damage.

· New OrBumps

- > Designed to run at 15 kA max, 1500 A_{rms},
- > 100% duty factor. ~16% Stronger.
- > Built with ferrite and coil cooling.
- > Radiation hardened construction.
- > Fit in the same footprint as existing magnets.
- > New Power Supply



Study of a Proposed Injection and new extraction Systems for the Fermilab Booster

A. Drozhdin

August 18, 2005

1 Conclusions

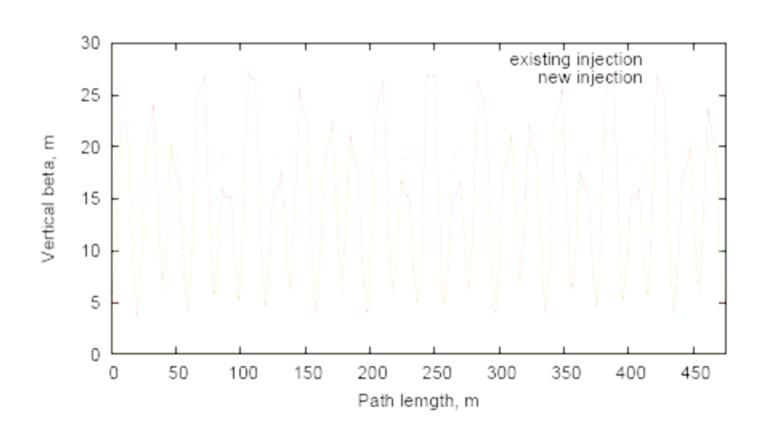
New injection scheme reduces vertical β-function by 23% from 27.3 m to 22.1 m.

There is a horizontal closed orbit deviation of $\sim 2.5 \ mm$ at injection because of gradient term in the bump magnets. It can be corrected by two fast (20-turn ramp) correctors of BL=0.005 kG-m.

Nonlinear field in the orbit bump magnets do not give a visible effect to the beam parameters during injection.

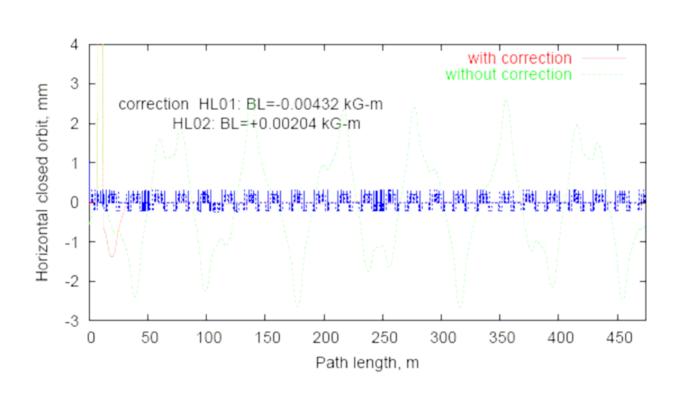


From Drozhdin's paper, p3





From Drozhdin's paper, p8





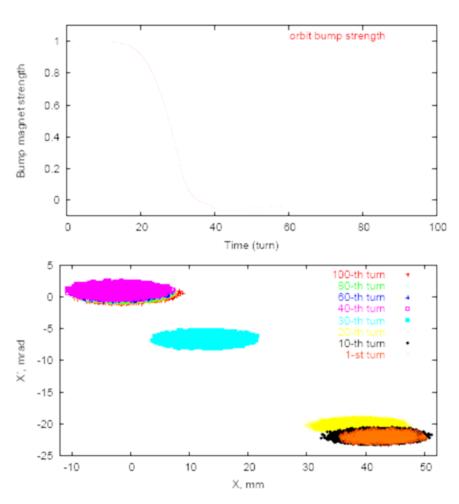
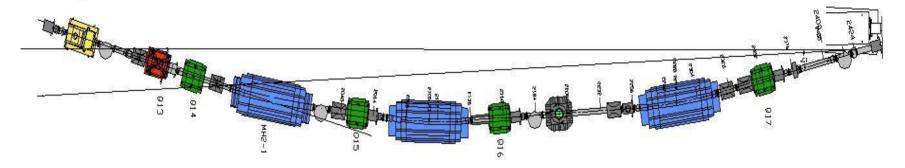


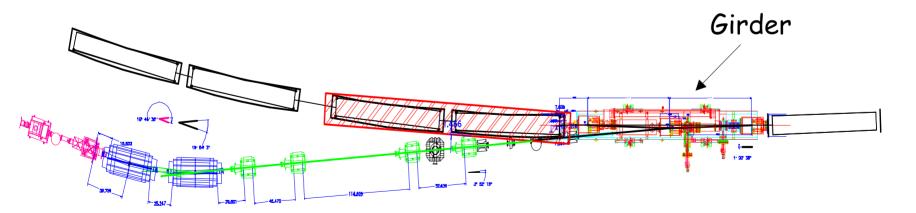
Figure 7: Orbit bump strength during injection (top) and circulating beam position (bottom) at turn No.1 (start of injection), No.10 (end of injection) and turns No.20, 30, 40, 60, 80 and 100 with nonlinear field harmonics in bump magnets.

PROTON PLAN Current vs New Injection Scheme Layout

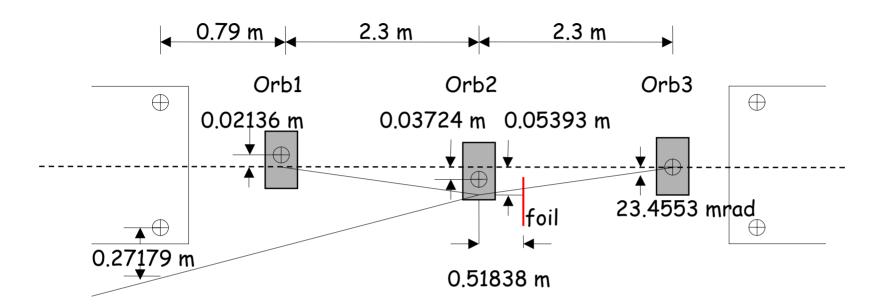
Current Scheme



New Scheme







Beam direction

New Injection Layout

